L Number	Hits	Search Text	DB	Time stamp
Number 14	751	(sensing adj (film or element or layer))	USPAT;	2004/07/26
		near3 (expose or exposing or exposed)	US-PGPUB;	05:50
		and the contract of the contra	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
15	919	(sensing adj (film or element or layer))	USPAT;	2004/07/26
		near3 (exposure or expose or exposing or	US-PGPUB;	05:50
		exposed)	EPO; JPO;	
		,	DERWENT;	
			IBM_TDB	
16	85	((sensing adj (film or element or layer))	USPAT;	2004/07/26
		near3 (exposure or expose or exposing or	US-PGPUB;	05:50
		exposed)) and ph	EPO; JPO;	
		exposed,, and pri	DERWENT;	
			IBM_TDB	
17	22	((sensing adj (film or element or layer))	USPAT;	2004/07/26
		near3 (exposure or expose or exposing or	US-PGPUB;	05:51
		exposed)).ti,ab,clm. and ph	EPO; JPO;	00.01
			DERWENT;	
			IBM_TDB	
18	3	((sensing adj (film or element or layer))	USPAT;	2004/07/26
		near3 (exposure or expose or exposing or	US-PGPUB;	05:52
		exposed)).ti,ab,clm. and ph.ti,ab,clm.	EPO; JPO;	03.32
		exposed//.tijabjeiiii aliu piiitijabjeiiii	DERWENT;	
			IBM_TDB	
19	1	((sensing adj (film or element or layer)) near	USPAT;	2004/07/26
	•	(exposure or expose or exposing or	US-PGPUB;	05:53
		exposed)).ti,ab,clm. and ph.ti,ab,clm.	EPO; JPO;	03.33
		exposed//itijabjeiiii alia pilitijabjeiiii	DERWENT;	
	İ		IBM_TDB	
20	462	((sensing adj (film or element or layer)) near	USPAT;	2004/07/26
-	402	(exposure or expose or exposing or	US-PGPUB;	05:53
		exposed))	EPO; JPO;	05.55
			DERWENT;	
			IBM_TDB	
21	41	((sensing adj (film or element or layer)) near	USPAT;	2004/07/26
		(exposure or expose or exposing or	US-PGPUB;	06:05
		exposed)) and ph	EPO; JPO;	
		• , F."	DERWENT;	
			IBM_TDB	
23	1	((sensing adj (film or element or layer)) near	USPAT;	2004/07/26
	-	(exposure or expose or exposing or	US-PGPUB;	06:05
		exposed)) near5 ((contact or electrode)	EPO; JPO;	
		near2 (below or under or above or over))	DERWENT;	
			IBM_TDB	
22	2	((sensing adj (film or element or layer)) near	USPAT;	2004/07/26
-	_	(exposure or expose or exposing or	US-PGPUB;	06:07
		exposed)) near10 ((contact or electrode)	EPO; JPO;	
		near2 (below or under or above or over))	DERWENT;	
		(IBM_TDB	

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24	2	((sensing adj (film or element or layer))	USPAT;	2004/07/26
		near2 (exposure or expose or exposing or	US-PGPUB;	06:08
		exposed)) near10 ((contact or electrode)	EPO; JPO;	
		near2 (below or under or above or over))	DERWENT;	
			IBM_TDB	
25	79	((sensing adj (film or element or layer))	USPAT;	2004/07/26
		near2 (exposure or expose or exposing or	US-PGPUB;	06:08
		exposed)) near10 ((contact or electrode))	EPO; JPO;	
			DERWENT;	
			IBM_TDB	
26	0	((sensing adj (film or element or layer))	USPAT;	2004/07/26
		near2 (exposure or expose or exposing or	US-PGPUB;	06:08
		exposed)) near10 ((contact or electrode))	EPO; JPO;	
		near10 (cavity or perforation)	DERWENT;	
			IBM_TDB	
27	6	((sensing adj (film or element or layer))	USPAT;	2004/07/26
		near2 (exposure or expose or exposing or	US-PGPUB;	06:11
		exposed)) near10 ((contact or electrode))	EPO; JPO;	
		and ph	DERWENT;	
			IBM_TDB	,
28	3	((sensing adj (film or element or layer))	USPAT;	2004/07/26
		near2 (exposure or expose or exposing or	US-PGPUB;	06:11
		exposed)) near10 (cavity or groove or	EPO; JPO;	
		concave or convex or perforation)	DERWENT;	
			IBM_TDB	